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Prof. Han S. Uhm

New Industry Convergence Technology R&D Center, Ajou University, Republic of Korea

Education

- 1968 B. S. in Physics, Seoul National University
- 1973 M. S. in Physics, University of Maryland, USA
- 1976 Ph. D. in Physics, University of Maryland, USA

Experience

- 1976 1978 Senior Research Associate in Department of Physics, University of Maryland
- 1978 1999 Executive Research Scientist in US Naval Surface Warfare Center
- 1999 2010 Professor in Ajou University, Korea
- 2003 2006 Director of Plasma Technology, Institute of Advanced Engineering, Korea
- 2006 Lifetime Member of Korean Academy of Science and Technology
- 2010 2015 Chair professor in Kwangwoon University, Korea
- 2015 2016 Research professor in GIST, Korea
- 2017 Present Research professor in Ajou University, Korea

Professional Activity

Member of American Physical Society

Member of Korean Physical Society and

Senior member of IEEE

Research Area

Researches on many areas in plasma field, carrying out basic studies related to shooting down of missiles. These researches include (1) charged particle beam propagation, (2) high power microwave generations, (3) neutron propagation, (4) electrical discharges in high pressure including display devices, (5) advanced material productions by plasma, and (6) plasma chemical reaction studies, resulting more than 470 SCI papers and more than 100 patent registrations in US, Korea and other countries. Present research concentrates on mass decontamination of biological and chemical warfare agents and on applications of the new technologies to industries, environments, energy, bio, agriculture and livestock areas. Awarded fifth Chungkwan award from Alumni Association of Seoul National University.